



Exercise 1

1-1. Consider the circuit of Fig.1.1.

- Using the simple model with $V_{Don} = 0.7V$, solve for I_D ;
- Find I_D and V_D using the ideal diode equation. Use $I_S = 10^{-14} A$ and $T=300 K$.

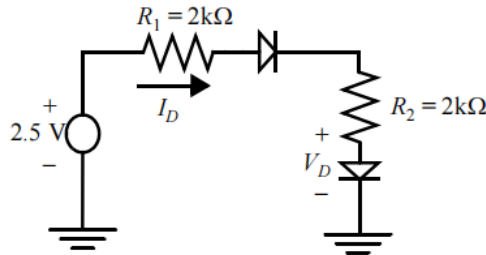


Fig.1.1

Answer:

$$a. \quad I_D = \frac{V_{in} - 2 \cdot V_{Don}}{R_1 + R_2} = \frac{2.5 - 2 \cdot 0.7}{4k\Omega} = 275\mu A$$

$$b. \quad I_S = 10^{-14} A, T = 300K, V_{Don} = 0.7V. I_D = I_S \times (e^{\frac{V_D q}{KT}} - 1) \quad \text{where} \quad \frac{KT}{q} = 26mV @ 300K$$

$$I_D = \frac{V_{in} - 2 \cdot V_{Don}}{R_1 + R_2} = I_S \times (e^{\frac{V_D q}{KT}} - 1) \quad \text{iterating on this expression we can obtain} \quad \frac{V_D}{I_D} = \frac{0.628V}{311\mu A}$$

1-2. For the circuit in Fig.1.2, $V_s=3.3 V$. Assume $A_D = 12 \mu m^2$, $\phi_0 = 0.65 V$, and $m=0.5$, $N_A = 2.5 \times 10^{16}$ and $N_D = 5 \times 10^{15}$.

- Is the diode forward- or reverse-biased?
- Find I_D and V_D ;
- Find the depletion region width, W_j , of the diode;
- Use the parallel-plate model to find the junction capacitance, C_j ;
- Set $V_s = 1.5 V$. Again using the parallel-plate model, explain qualitatively why C_j increases.

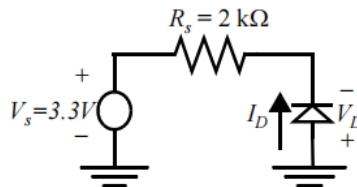


Fig.1.2

Answer:

- Reverse biased
- $I_D = I_{REV} = -I_S \approx 0, V_D = -V_s = -3.3V$

$$c. \quad W_j = \sqrt{\frac{2 \cdot \epsilon_{si}}{q} \times \frac{N_A + N_D}{N_A N_D} \times (\phi_0 - V_D)}, q = 1.6 \times 10^{-19} C, V_D = -V_S = -3.3V,$$

$$\epsilon_{si} = 11.7\epsilon_0 = 1.035 \times 10^{-10} F/m, N_A = 2.5 \times \frac{10^{16}}{cm^3}, N_D = 5 \times \frac{10^{15}}{cm^3}.$$

$$W_j = 1.107 \times 10^{-4} cm.$$

$$d. \quad C_j = \frac{\epsilon_{si} \cdot A_D}{W_j}, A_D = 12 \times 10^{-8} cm^2, C_j = 1.12 \times 10^{-15} F.$$

e. $V_{SNEW} = 1.5V < V_{SOLD} = 3.3V$. The new voltage reduces the reverse bias of the PN junction, hence the width of the depletion region, W_j , decreases. As you bring the plates of capacitor together, the capacitance increases.

1-3. Fig.1.3 shows NMOS and PMOS devices with drains, source, and gate ports annotated. Determine the operation region (saturation, linear, or cut-off) and the drain current I_D for each of the biasing configurations given in table. Assume the model parameters from Table.1.1, $V_{BS}=0$ and $W/L = 1, L=1\mu m$, fill the table

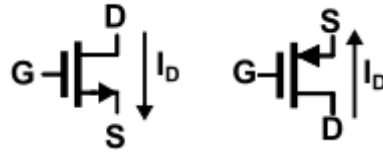


Fig.1.3

Answer:

	$V_{GS}(V)$	$V_{DS}(V)$	Operation region	I_D
NMOS	2.5	2.5	saturation	392.04uA
	3.3	2.2	linear	726uA
	0.6	0.1	cut-off	0
PMOS	-0.5	-1.25	cut-off	0
	-2.5	-1.8	saturation	176.58uA
	-2.5	-0.7	linear	101.5uA

NMOS :1. Saturation $I_D = k'_n \frac{W}{L} (V_{GS} - V_{TH})^2 (1 + \lambda V_{DS}) = 392.04 \mu A;$

2. linear $I_D = 2 \times k'_n \frac{W}{L} \left((V_{GS} - V_{TH}) V_{DS} - \frac{V_{DS}^2}{2} \right) = 726 \mu A;$

3. cut-off $I_D = 0,$

PMOS : 1. cut-off $I_D = 0,$

2. Saturation $I_D = k'_p \frac{W}{L} (V_{GS} - V_{TH})^2 (1 + \lambda V_{DS}) = 176.58 \mu A$

3. linear $I_D = 2 \times k'_p \frac{W}{L} \left((V_{GS} - V_{TH}) V_{DS} - \frac{V_{DS}^2}{2} \right) = 101.5 \mu A$

1-4. An NMOS device is plugged into the test configuration shown below in Fig .1.4 The input V_{in} is 2V. The current source draws a constant current of 50 μA . R is a variable resistor between 10k Ω and 30 k Ω . Transistor M1 has following transistor parameters: $k' = 110 \mu \text{ V/A}^2$, $V_T = 0.7\text{V}$, and $V_{DSAT} = 0.6\text{V}$, and has a $W/L = 2.5\mu\text{m}/0.25\mu\text{m}$. For simplicity, the body effect and channel length modulation can be neglected, i.e $\lambda=0$, $\gamma=0$.

- a) When $R = 10\text{k}\Omega$ find the operation region, V_D and V_S .
b) For the case of $R = 10\text{k}\Omega$, would V_S increase or decrease if $\lambda \neq 0$. Explain qualitatively.

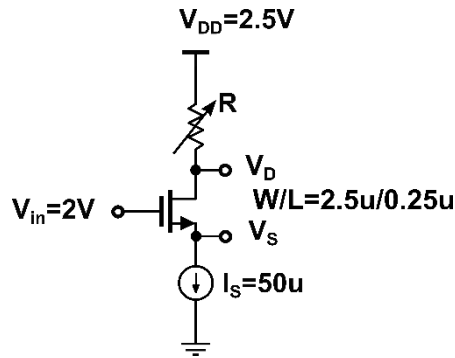


Fig.1.4

Answer:

- a. When $R = 10\text{K}$, $V_D = V_{DD} - IR = 2.5 - 50 \times 10^{-6} \times 10^4 = 2.5 - 0.5 = 2\text{V}$. Assume the device is in saturation $I_D = k'_n \frac{W}{L} (V_{GS} - V_{TH})^2 = 50\mu\text{A}$ find $V_{GS} - V_{TH} = 0.213\text{V}$, so $V_{GS} = 0.213 + 0.7\text{V} = 0.913\text{V}$,
 $V_S = 1.087\text{V}$. $V_{GS} = 0.913\text{V}$, $V_{DS} = 1.087\text{V}$ device in the saturation.
- b. Increase. V_D is fixed due to constant current. $1 + \lambda V_{DS}$ term would try to increase the current more than 50uA, thus V_{GS} needs to reduce by increase V_S .

Thinking Questions(optional)

- 1-5. Show that two MOS transistors connected in parallel with channel widths of W_1 and W_2 and identical channel lengths of L can be modeled as one equivalent MOS transistor whose width is $W_1 + W_2$ and whose length is L , as shown in Fig.1.5 Assume the transistors are identical except for their channel widths.

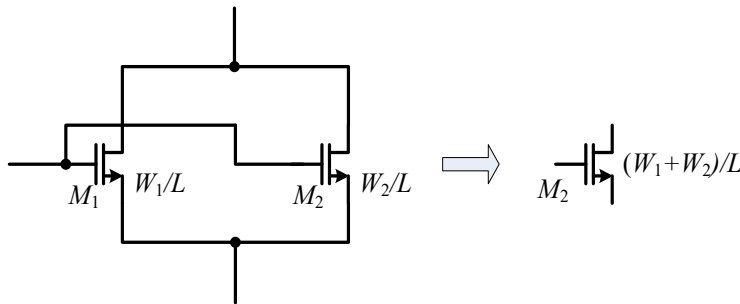


Fig.1.5

Answer:

For $V_{DS} \leq V_{GS} - V_{TH}$

$$I_{D1} = \mu C_{OX} \frac{W_1}{L} [(V_{GS} - V_{TH})V_{DS} - \frac{1}{2}V_{DS}^2]$$

$$I_{D2} = \mu C_{OX} \frac{W_2}{L} [(V_{GS} - V_{TH})V_{DS} - \frac{1}{2}V_{DS}^2]$$

.....

$$I_{Dn} = \mu C_{OX} \frac{W_n}{L} [(V_{GS} - V_{TH})V_{DS} - \frac{1}{2}V_{DS}^2]$$

$$\therefore I_D = I_{D1} + I_{D2} + \dots + I_{Dn} = \mu C_{OX} \frac{W_1 + W_2 + \dots + W_n}{L} [(V_{GS} - V_{TH})V_{DS} - \frac{1}{2}V_{DS}^2]$$

For $V_{DS} \geq V_{GS} - V_{TH}$

$$I_D = I_{D1} + I_{D2} + \dots + I_{Dn} = \frac{1}{2} \mu C_{OX} \frac{W_1 + W_2 + \dots + W_n}{L} (V_{GS} - V_{TH})^2$$

Thus the equivalent length = L and the equivalent width = $W_1 + W_2 + \dots + W_n$.

- 1-6. Show that two MOS transistors connected in series with channel lengths of L_1 and L_2 and identical channel widths of W can be modeled as one equivalent MOS transistor whose width is W and whose length is $L_1 + L_2$, as shown in Fig. 1.6. Assume the transistors are identical except for their channel lengths. Ignore the body effect and channel-length modulation.

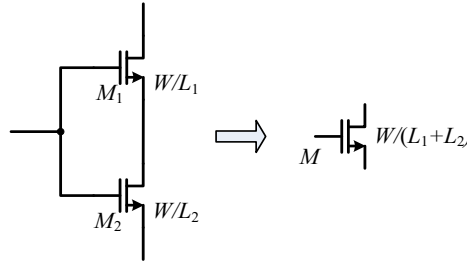
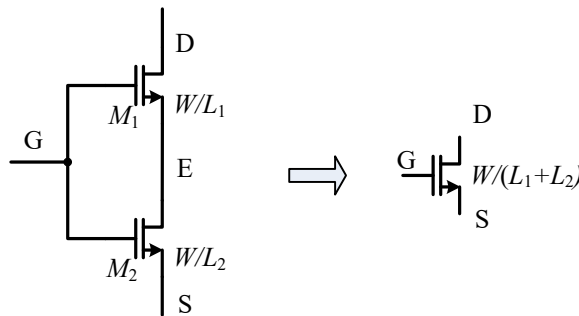


Fig.1.6

Answer:



- (1) When $V_{GS} < V_{TH}$ and $V_{GE} < V_{GS} < V_{TH}$, the MOSFETs are in cut off.

(2) While M1 operates in triode ($V_{DE} < V_{GE} - V_{THN}$), that is equivalent to $V_{DE} + V_{ES} < V_{GE} + V_{ES} - V_{THN}$, i.e. $V_{DS} < V_{GS} - V_{THN}$.

Thus M2 operates in triode, too.

Thus

$$I_{D1} = \mu_n C_{OX} \frac{W}{L_1} [(V_{GE} - V_{TH})V_{DE} - \frac{1}{2}V_{DE}^2] \quad (1)$$

$$I_{D2} = \mu_n C_{OX} \frac{W}{L_2} [(V_{GS} - V_{TH})V_{ES} - \frac{1}{2}V_{ES}^2] \quad (2)$$

Since

$$V_{DS} = V_{DE} + V_{ES} \quad (3)$$

$$V_{GE} = V_{GS} - V_{ES} \quad (4)$$

$$I_{D1} = I_{D2} = I_D \quad (5)$$

It can be derived from equations (1), (2), (3), (4) and (5) that

$$\begin{aligned} (V_{GS} - V_{TH})V_{ES} - \frac{1}{2}V_{ES}^2 &= \frac{L_2}{L_1} [(V_{GS} - V_{TH} - V_{ES})(V_{DS} - V_{ES}) - \frac{1}{2}(V_{DS} - V_{ES})^2] \\ &= \frac{L_1}{L_1 + L_2} [(V_{GS} - V_{TH})V_{DS} - \frac{1}{2}V_{DS}^2] \end{aligned}$$

So we can get $I_D = \mu_n C_{OX} \frac{W}{L_1 + L_2} [(V_{GS} - V_{TH})V_{DS} - \frac{1}{2}V_{DS}^2]$

(3) While M1 operates in saturation ($V_{DE} > V_{GE} - V_{THN}$). It means $V_{DE} + V_{ES} > V_{GE} + V_{ES} - V_{THN}$, i.e. $V_{DS} > V_{GS} - V_{THN}$.

$V_E = V_G - V_{GE} < V_G - V_{THN}$, it means $V_{ES} < V_{GS} - V_{THN}$. M2 operates in triode.

So

$$I_{D1} = \frac{1}{2} \mu_n C_{OX} \frac{W}{L_1} (V_{GE} - V_{TH})^2 \quad (1)$$

$$I_{D2} = \frac{1}{2} \mu_n C_{OX} \frac{W}{L_2} [2(V_{GS} - V_{TH})V_{ES} - V_{ES}^2] \quad (2)$$

$$V_{DS} = V_{DE} + V_{ES} \quad (3)$$

$$V_{GE} = V_{GS} - V_{ES} \quad (4)$$

$$I_{D1} = I_{D2} = I_D \quad (5)$$

It can be derived from equations (1), (2), (3), (4) and (5) that

$$I_D = \frac{1}{2} \mu_n C_{ox} \frac{W}{L_1 + L_2} (V_{GS} - V_{TH})^2$$

That just like a MOSFET operating in saturation, which has a length of $L_1 + L_2$ and a width of W . It can be deduced similarly that n MOSFETs in series acts as a MOSFET with an aspect ratio of $W/(L_1 + L_2 + \dots L_n)$.

Table.1.1

Parameter Symbol	Parameter Description	Typical Parameter Value		Units
		n-Channel	p-Channel	
V_{T0}	Threshold voltage ($V_{BS}=0$)	0.7	-0.7	V
K'	Transconductance parameter (in saturation)	110.0	50.0	$\mu A/V^2$
γ	Bulk threshold parameter	0.4	0.57	$V^{1/2}$
λ	Channel length modulation parameter	0.04 (L=1 μm) 0.01 (L=2 μm)	0.05 (L=1 μm) 0.01 (L=2 μm)	V^{-1}
$2 \Phi_f $	Surface potential at strong inversion	0.7	0.8	V

$$*K' = \frac{1}{2} \mu C_{ox}$$